



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80575

Hiroo TAKIZAWA, et al.

Appln. No.: 10/804,144

Group Art Unit: 1711

Confirmation No.: 6372

Examiner: Not yet assigned

Filed: March 19, 2004

For: TWO-PHOTON ABSORBING POLYMERIZABLE COMPOSITION AND  
POLYMERIZATION PROCESS THEREOF

**INFORMATION DISCLOSURE STATEMENT**  
**UNDER 37 C.F.R. §§ 1.97 and 1.98**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant hereby notifies the U.S. Patent and Trademark Office of the documents which are listed on the attached PTO/SB/08 A & B (modified) form and/or listed herein and which the Examiner may deem material to patentability of the claims of the above-identified application.

One copy of each of the listed documents, other than any U.S. patents and patent publications, is submitted herewith.

The present Information Disclosure Statement is being filed: (1) No later than three months from the application's filing date; (2) Before the mailing date of the first Office Action on the merits (whichever is later); or (3) Before the mailing date of the first Office Action after

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filing a request for continued examination (RCE) under §1.114, and therefore, no Statement under 37 C.F.R. § 1.97(e) or fee under 37 C.F.R. § 1.17(p) is required.

The submission of the listed documents is not intended as an admission that any such document constitutes prior art against the claims of the present application. Applicant does not waive any right to take any action that would be appropriate to antedate or otherwise remove any listed document as a competent reference against the claims of the present application.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this paper is attached.

Respectfully submitted,



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WASHINGTON OFFICE  
**23373**  
CUSTOMER NUMBER

Date: June 23, 2004

Substitute for Form 1449 A & B/PTO		Complete if Known O I P C	
<b><u>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</u></b>			
<i>(use as many sheets as necessary)</i>			
Sheet	1	of	1
		Attorney Docket Number	
		Q80575	
JUN 23 2004 U.S. PATENT AND TRADEMARK OFFICE			

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

## **NON PATENT LITERATURE DOCUMENTS**

Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation <sup>6</sup>
		Brian H. Cumpston et al., "Two-photon polymerization initiators for three-dimensional optical data storage and microfabrication", Nature, Vol. 398, 1999, pp. 51-54	
		Kevin D. Belfield et al., "Multiphoton-absorbing organic materials for microfabrication, emerging optical applications and non-destructive three-dimensional imaging", J. Phys. Org. Chem., Vol. 13, 2000, pp. 837-849	
		Chengde Li et al., "Two-photon microstructure-polymerization initiated by a coumarin derivative/iodonium salt system", Chem. Phys. Lett., Vol. 340, 2001, pp. 444-448	
		Kevin D. Belfield et al., "Near-IR Two-Photon Photoinitiated Polymerization Using a Fluorone/Amine Initiating System", J. Am. Chem. Soc., Vol. 122, 2000, pp. 1217-1218	
		Shoji Maruo et al., "Three-dimensional microfabrication with two-photon-absorbed photopolymerization", Opt. Lett., Vol. 22, 1997, pp. 132-134	

Examiner Signature		Date Considered	
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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